

Complexometric Determination of Thallium(III) using Ethanethiol as a Selective Masking Agent

J. Karthikeyan,^a P. Parameshwara,^a A. Nityananda Shetty^{*,a} and Prakash Shetty^b

^aDepartment of Chemistry, National Institute of Technology Karnataka, Surathkal Srinivasnagar-575 025 Karnataka, India

^bDepartment of Chemistry, Manipal Institute of Technology, Manipal-576 119 Karnataka, India

Um método complexométrico simples e seletivo é proposto para a determinação de tálio na presença de outros metais, pela habilidade do etanetiól em mascarar seletivamente íons tálio (III). Em solução, o tálio presente foi inicialmente complexado com um excesso conhecido de EDTA, sendo o excesso titulado com uma solução padrão de sulfato de zinco em pH 5-6 (hexamina), usando-se xilenol como indicador. Uma solução aquosa de etanetiól 0,3 % foi então adicionada para deslocar o EDTA do complexo Tl(III)-EDTA. O EDTA livre foi titulado com solução padrão de sulfato de zinco, como anteriormente. Resultados reprodutíveis e precisos foram obtidos na faixa de 3,70 mg a 74,07 mg de Tl(III), com erro relativo menor do que $\pm 0,44$ % e um coeficiente de variação menor do que 0,27 %. A interferência de vários íons foi estudada e o método foi usado para análise de tálio em misturas de ligas sintéticas e também em complexos.

A simple and selective complexometric method for the determination of thallium in presence of other metal ions is proposed based on the selective masking ability of ethanethiol towards thallium(III). Thallium present in a given sample solution is first complexed with a known excess of EDTA and the surplus EDTA is titrated with standard zinc sulphate solution at pH 5-6(hexamine) using xylenol orange as the indicator. A 0.3% aqueous solution of ethanethiol is then added to displace EDTA from the Tl(III)-EDTA complex. The released EDTA is titrated with standard zinc sulphate solution as before. Reproducible and accurate results are obtained for 3.70 mg to 74.07 mg of Tl (III) with relative error less than $\pm 0.44\%$ and coefficient of variation not more than 0.27%. The interference of various ions was studied and the method was used for the analysis of thallium in its synthetic alloy mixtures and also in complexes.

Keywords: thallium determination, masking agent, ethanethiol

Introduction

Thallium alloys and its complexes find various applications in diverse fields such as photo-electric cells, insoluble anodes, corrosion inhibitors and fungicides. Considering these excellent and extensive applications of thallium alloys and its complexes, a reliable and rapid method is often essential for the determination of thallium in a single stage.

Owing to poor selectivity, earlier complexometric methods,^{1,2} for thallium could not be used for the

determination in its alloys. Complexometric titrations particularly those involving masking and demasking technique are of considerable importance as they provide simple and rapid method for the determination of a specific desired metal ion in the presence of associated metal ions. In the determination of thallium by this technique, it is first complexed with EDTA followed by selective decomposition of Tl-EDTA complex with the suitable masking agent. The released EDTA is back titrated with suitable titrant. Literature survey shows that a number of sulphur-nitrogen donor ligands such as thiopyrene,³ thiosemicarbazide,⁴ hydrazine sulphate,⁵ 2-mercapto ethanol,⁶ thiocarbohydrazide,⁷ ascorbic acid,⁸

* e-mail: nityashreya@rediffmail.com

DL-cysteine,⁹ 3-mercapto-1,2-propanediol,¹⁰ ethylene thiourea,¹¹ sodium sulfite,¹² 2-thiazoline-2-thiol,¹³ hydroxylamine hydrochloride,¹⁴ semicarbazide hydrochloride,¹⁵ thiosulfate,¹⁶ thiourea,¹⁷ cysteamine hydrochloride,¹⁸ thioglycolic acid,¹⁹ oxalic acid,²⁰ *etc.* have been used as selective masking agents in the complexometric determination of Tl(III). Some of these methods either require heating or re-adjustment of pH for the quantitative release of EDTA from Tl-EDTA complex. In many of the methods, Cu(II) interferes and many other ions show interference in other methods. A comparison of the reported methods with the presently proposed method is given in the Table 1.

The present investigation describes, ethanethiol as a selective masking agent in the complexometric determination of thallium(III). The effects of foreign ions have been studied and application of the method in the determination of thallium in its complexes and synthetic alloy mixtures has been reported.

Experimental

Reagents and chemicals

All reagents used were of analytical or chemically pure grade. A Thallium nitrate solution was prepared as per the reported procedure.²¹ A known weight of thallos nitrate was dissolved in minimum amount of water, oxidized to Tl(III) by alkaline bromine, separated and purified by precipitation as Tl(OH)₃. It was then dissolved in dilute HCl, made up to the mark with distilled water and standardized by the chromate method and thionalide method.²² Zinc sulphate solution (0.02 mol L⁻¹) was prepared from an analytical reagent grade sample, and

was standardized gravimetrically by the oxinate method and quinaldinate method.²² EDTA solution (~0.04 mol L⁻¹) was prepared by dissolving the di-sodium salt of EDTA in distilled water. Freshly prepared 0.5 % aqueous solution of the xylenol orange indicator was used. Ethanethiol was used as a 0.3 % solution in distilled water. Solutions of various metal ions were prepared by dissolving the appropriate metal salts in distilled water or with suitable acids.

Procedure

To an aliquot of the solution containing 3.70 –74.07 mg of thallium solution and varying amounts of diverse metal ions taken in a 250 mL conical flask, an excess of 0.04 mol L⁻¹ EDTA solution was added. The solution was diluted with 20 mL of distilled water. The pH of the solution was adjusted to between 5-6 by adding solid hexamine. Excess EDTA was back titrated with standard zinc sulphate solution to the sharp color change of xylenol orange indicator from yellow to red. A 0.3 % aqueous solution of ethanethiol was added (just above 1:10 molar ratio M:L), shaken well and allowed to stand for two minutes. The released EDTA was back titrated with standard zinc sulphate solution to the same end point as before. The second titre value is equivalent to the thallium content present in the aliquot.

Analysis of thallium complexes

A number of thallium(I) complexes with 5-amino-2-mercapto-1,3,4-thiadiazole, 4-amino-5-mercapto-3-methyl-1,2,4-triazole, 4-amino-3-ethyl-5-mercapto-1,2,4-triazole, 4-amino-5-mercapto-3-n-propyl-1,2,4-triazole

Table 1. Comparison of the reported reagents with the proposed reagent

Reagent	Interfering ions	Reference
Thiosemicarbazide	Hg(II), Cu(II), Fe(II), Pd(II), Sn(II), Cr(III), Bi(III) and Al(III)	4
Hydrazine sulphate	Cr(III), Mn(II), Sn(IV), Pd(II), Ga(III), In(III) and Al(III)	5
2-mercaptoethanol	Pd(II), Hg(II), Cu(II), Cr(III) and Sn(IV)	6
Thiocarbohydrazide	Cu(II), Pd(II), Hg(II), Bi(III), Zr(III) and Sn(IV)	7
Ascorbic acid	Ag(I), Cu(II), Hg(II), Pb(II), Au(III), Sb(IV) and Sn(IV)	8
DL-Cysteine	Cu(II), Pd(II) and Hg(II)	9
3-Mercapto-1,2-propanediol	Pd(II), Hg(II), Cu(II), Cr(III) and Sn(IV)	10
Ethylene thiourea	Ag(I), Hg(II) and Sn(IV)	11
Sodium sulfite	Hg(II), Pd(II) and Sn(IV)	12
2-Thiazoline-2-thiol	Hg(II), Pd(II), Cu(II), Fe(III), Al(III) V(III), Cr(III), Ce(IV) and Sn(IV),	13
Hydroxylamine hydrochloride	Ag(I), Hg(II), Pd(II), Au(III), Sb(IV) and Sn(IV)	14
Thiosulfate	Pd(II), Hg(II), Au(III), Zr(III) and Sn(IV)	16
Thiourea	Cu(II), Pd(II), Hg(II), Zr(III) and Sn(IV)	17
Cysteamine hydrochloride	Cu(II), Pd(II) and Sn(IV)	18
Thioglycolic acid	Pd(II), Hg(II), Cu(II), Cr(III) and Sn(IV)	19
Ethanethiol	Hg(II), Pd(II) and Sn(IV). For Hg(II) interference obviated by using acetyl acetone.	Proposed reagent

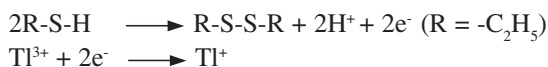
were prepared and purified as *per* the reported methods.^{28,29} A known weight of the complex was decomposed by evaporation to near dryness with aqua-regia. The residue was then cooled, dissolved in 3 mL of dilute HNO₃, and made up to 250 mL with distilled water. Aliquots of the made up solution were used for titration as per the proposed method using ethanethiol as a masking agent.

Result and Discussions

Mechanism of demasking

Generally, a metal, which can exist in two different oxidation states, differs in its tendency to form a stable complex with EDTA at different oxidation states. Thallium is one such element, which forms a stable complex with EDTA (log K=22.5) in its trivalent state,²³ but shows little tendency for complexation with EDTA in its monovalent state.²⁴ Even if thallium (I) forms complex with EDTA it may do so only in the basic medium (pH 8-9) and complete decomposition of Tl(I)-EDTA complex takes place in the acidic medium.²⁵ Therefore, the redox behavior of Tl(III)-Tl(I) can be conveniently employed in acidic medium for its complexometric determination by demasking technique.

Being a good reducing agent, ethanethiol effectively reduces Tl(III) to Tl(I) by a 2-electron change process.²⁶ The redox reaction can be represented as follows



Ethanethiol thus selectively demasks thallium from Tl(III)-EDTA complex through a change in the oxidation state of thallium (reduction) and thereby releases EDTA quantitatively. Besides changing the oxidation state of thallium, ethanethiol forms a stable and soluble complex with Tl(I) so formed. The +1 oxidation state of thallium in its complex was confirmed by spot test,²⁷ a red precipitate was formed when a solution of the complex in dilute hydrochloric acid was treated with a drop each of bismuth nitrate solution and sodium iodide solution.

Effect of reagent concentration

Preliminary experimental results showed that addition of ethanethiol in 1:10 molar ratio (M:L) was required for the quantitative release of EDTA from Tl(III)-EDTA complex at room temperature. However, no adverse effects on the results were observed even on adding 10 fold excess over the required quantity of the reagent. In all our

subsequent determinations the concentration of the reagent was maintained at slightly above the required molar ratio.

Accuracy and precision

In order to study the accuracy and precision of the method, determinations of thallium in the concentration range of 3.70–74.07mg were carried out under optimized experimental conditions. These results are presented in Table 2. The results show that the maximum relative error does not exceed $\pm 0.44\%$ and coefficient of variation not more than $\pm 0.27\%$. From these results, it is reasonable to infer that the proposed method is precise and accurate.

Table 2. Precision and accuracy in the determination of Tl(III)

Thallium (mg)		Relative error (%)	Standard deviation	Coefficient of variation (%)
Taken	Found ^a			
3.70	3.69	-0.27	0.01	0.27
7.40	7.40	0.00	0.02	0.27
11.20	11.18	-0.18	0.03	0.26
18.80	18.76	-0.21	0.05	0.26
37.03	37.06	+0.08	0.05	0.13
74.07	74.10	+0.04	0.03	0.04

^aAverage of six determinations.

Effect of foreign ions

In order to ascertain the possible interference of the diverse ions, thallium determination was carried out with an aliquot containing 11.20 mg of Tl(III) in the presence of various metal ions and anions. The non-interfering ions are listed in Table 3. However, Pd(II), Hg(II), Cr(III) and Sn(IV) interfere severely with positive error. The interference of Pd(II), Hg(II) and Sn(IV) is due to the release of EDTA from their EDTA complexes on the addition of the reagent. The interference of Cr(III) is mainly due to the deep purple color of its EDTA complex, which makes the detection of the end point rather difficult. In the case of Hg(II), interference can be avoided by pre-masking the metal ions with acetyl acetone.

Application

In order to explore the utility of the proposed method, quantitative analysis of complexes and synthetic mixtures of thallium were carried out. The analytical reports of such samples are given in Tables 4 & 5. From these results it can be concluded that the proposed method can be conveniently employed for rapid analysis of such samples.

Table 3. Determination of 11.20 mg of Tl(III) in the presence of diverse metal ions

Metal ions	Quantity added (mg)	Thallium found ^a (mg)	Relative error (%)
Mg(II)	30	11.18	-0.17
Mn(II)	40	11.17	-0.26
Co(II)	150	11.21	+0.09
Ni(II)	150	11.18	-0.17
Cu(II)	100	11.18	-0.17
Zn(II)	200	11.20	0.00
Cd(II)	100	11.22	+0.17
Pb(II)	200	11.20	0.00
La(II)	200	11.20	0.00
Hg(II) ^b	15	11.21	+0.09
Y(III)	200	11.20	0.00
Ir(III)	25	11.16	-0.35
Al(III)	50	11.16	-0.35
Bi(III)	15	11.18	-0.17
Rh(III)	50	11.20	0.00
Ru(III)	10	11.17	-0.26
Au(III)	20	11.19	-0.09
As(III)	50	11.20	0.00
Sb(IV)	10	11.50	-0.44
Pt(IV)	50	11.20	0.00
Se(IV)	100	11.22	+0.17
U(VI)	50	11.18	-0.17
W(VI)	30	11.16	-0.35
Cl ⁻	200	11.20	0.00
CH ₃ COO ⁻	200	11.18	-0.17
Phosphate	100	11.20	0.00
Citrate	100	11.22	+0.17
Tartarate	100	11.21	+0.09
Acetate	50	11.22	+0.17
Borate	150	11.21	+0.09
Sulphate	75	11.20	0.00
Oxalate	100	11.21	+0.09

^aAverage of four determinations; ^bpre-masked using acetyl acetone.

Table 4. Analysis of thallium complexes

Complexes	Thallium calculated (%)	Thallium found ^a (%)	Relative error (%)
Tl(C ₄ H ₇ N ₄ S) ^a	58.83	58.98	+0.25
Tl(C ₅ H ₅ N ₄ S) ^b	61.37	61.30	-0.11
Tl(C ₃ H ₉ N ₄ S) ^c	56.55	56.50	-0.08
Tl(C ₂ H ₂ N ₃ S) ^d	60.73	60.56	-0.27

Thallium complexes of ^a4-amino-5-mercapto-3-ethyl-1,2,4-triazole; ^b4-amino-5-mercapto-3-methyl-1,2,4-triazole; ^c4-amino-5-mercapto-n-propyl-1,2,4-triazole; ^d5-amino-2-mercapto-1,3,4-thiadiazole. ^aAverage of four determinations.

Table 5. Determination of thallium in synthetic mixtures

Alloy composition	Percentage of thallium	Thallium found (%) ^a	Relative error (%)
Tl + Zn + Cd	18.80	18.77	-0.16
Tl + Pb + Sb	11.20	11.19	-0.08
Tl + Se + Co	37.03	37.05	+0.05
Tl + Pt + Pb	74.07	74.09	+0.02
Tl + Cu + Zn	37.03	37.04	+0.02
Tl + Y + Zr	11.20	11.20	0.00

^aAverage of four determinations.

Conclusions

The method is simple and rapid, does not require any heating for the quantitative release of EDTA from Tl(III)-EDTA complex. The reagent does not form any precipitate either with Tl(III) or with the titrant under the experimental conditions. This facilitates the detection of sharp end point. The proposed method is fairly selective for the rapid analysis of thallium in the presence of various other ions.

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